

Express Mail No.: EB 270750868 US

SUBSTITUTE SPECIFICATION CLEAN VERSION

METHOD AND APPARATUS FOR  
RECOGNIZING A STRUCTURE TO BE  
APPLIED ONTO A SUBSTRATE WITH  
MULTIPLE CAMERAS

ABSTRACT OF THE DISCLOSURE

A method and apparatus are provided for automatic application and monitoring of a structure to be applied onto substrate. A plurality of cameras positioned around an application facility are utilized to monitor the automatic application of a structure on a substrate by means of a stereometry procedure. Three-dimensional recognition of a reference contour position results in the overlapping area to be used for gross adjustment of the application facility prior to applying the structure.